| Electronic Pate | ent App | lication Fe | e Transmit | tal | | | | |
|---|-----------|---|------------|--------|-------------------------|--|--|--|
| Application Number: | 105 | 10565505 | | | | | | |
| Filing Date: | 06 | 06-Jul-2006 | | | | | | |
| Title of Invention: | Dis: | Dissolution inhibitors in photoresist compositions for microlithography | | | | | | |
| First Named Inventor/Applicant Name: | Sha | Shahab Jahromi | | | | | | |
| Filer: | Bry | Bryan H. Davidson/Dawn Barbour | | | | | | |
| Attorney Docket Number: | вн | BHD-4662-138 | | | | | | |
| Filed as Large Entity | | | | | | | | |
| U.S. National Stage under 35 USC 371 Fi | ling Fees | ; | | | | | | |
| Description | | Fee Code | Quantity | Amount | Sub-Total in USD(\$) | | | |
| Basic Filing: | | | | | | | | |
| Pages: | | | | | | | | |
| Claims: | | | | | | | | |
| Claims in excess of 20 | | 1615 | 8 | 52 | 416 | | | |
| Miscellaneous-Filing: | | | 1 | | | | | |
| Petition: | | | | | | | | |
| Patent-Appeals-and-Interference: | | | | | | | | |
| Post-Allowance-and-Post-Issuance: | | | | | | | | |
| Extension of Times | | | | | | | | |

| Description | Fee Code | Quantity | Amount | Sub-Total in USD(\$) |
|--|----------|----------|--------|-------------------------|
| Extension - 1 month with \$0 paid | 1251 | 1 | 130 | 130 |
| Miscellaneous: | • | | | |
| Submission-Information Disclosure Stmt | 1806 | 1 | 180 | 180 |
| | Tot | 726 | | |